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Rice polishing apparatus for removing rice bran has inclined guide rails supporting conveyance board that consists of semicircular recesses arranged with wire net for accommodating polish roller

Patent Assignee: MIC KK (MICM-N)

Number of Countries: 001 Number of Patents: 001

Patent Family:

Patent No	Kind	Date	Applicat No	Kind	Date	Week
JP 2000042429	A	20000215	JP 98211006	A	1998072	200019 B

Priority Applications (No Type Date): JP 98211006 A 19980727

Patent Details:

Patent No	Kind	Lan	Pg	Main IPC	Filing Notes
JP 2000042429	A		5	B02B-003/00	

Abstract (Basic): JP 2000042429 A

NOVELTY - Rice polishing apparatus has reciprocatable conveyance board (1) made of rubber material supported between inclined guide rails. Conveyance board has semicircular recesses (3) arranged with wirenet (4) for accommodating motor driven polish roller (9) to remove rice bran.

USE - For removing rice bran.

ADVANTAGE - Rice bran is removed efficiently with wirenet in the recess by using polishing roller. Thereby shelf life is improved. Since polishing is done without using water, the rice flavor is maintained for a long period and glossy surface is formed.

DESCRIPTION OF DRAWING(S) - The figure shows the enlarged principal part view of rice polishing apparatus.

Conveyance board (1)

Semicircular recess (3)

Wirenet (4)

Polish roller (9)

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Title Terms: RICE; POLISH; APPARATUS; REMOVE; RICE; BRAN; INCLINE; GUIDE; RAIL; SUPPORT; CONVEY; BOARD; CONSIST; SEMICIRCULAR; RECESS; ARRANGE; WIRE; NET; ACCOMMODATE; POLISH; ROLL

Derwent Class: D13; P41

International Patent Class (Main): B02B-003/00

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